

New generation of photoresist film that offer an alternative to plotter-cut or hand-cut vinyl!

AVAILABILITY

MMHD (10 mil = 150 micron)

MMHD is photoresist film that is similar to MMX, but designed for higher detail masks.

MMX (10 mil = 250 micron)

MMX provides deep etching ability similar to vinyl while offering the quick and easy process of a photoresist. Achieve better image quality with no hassle of weeding!

REQUIRED EQUIPMENT

Computer generated artwork and inkjet / laser printer
UV exposure unit , Washout equipment
Sandblasting cabinet with media



BLASTING SETTINGS

Maximum pressure 80-100 PSI (5-7 bars)
Recommended grit size 60-180 mesh

Made stencils can be used in years

Superior resolution compared to standard vinyl

Excellent contrast for easy positioning

BLACK = BLAST

Self adhesive

Deep etching ability

Detailed resolution

Simple clean up

Zero adhesive residue

No hassle of weeding

**Any further question?
We are happy to help you!**

FLYER